AMENDMENTS TO THE SPECIFICATION

Please amend the paragraphs starting on these lines as follows:

Page 6, line 23:

Preferred embodiments of this invention will be described hereinafter, referring to

drawings. Fig. 1 illustrates a light diffusion sheet in which an a light diffusion layer 4 comprising

a transparent resin layer 2 having fine particles 3 dispersed therein is formed on a transparent

substrate 1. Fine particles 3 currently dispersed in the transparent resin layer 2 forms unevenness

shape on the surface of the light diffusion layer 4. In addition, although Fig. 1 illustrates a case

where the transparent resin layer 2 consists of one layer, an light diffusion layer may also be formed

of two or more transparent resin layers by forming separately transparent resin layer including fine

particles between the transparent resin layer 2 and the transparent substrate 1.

Page 9, line 19:

A forming method of the transparent resin layer 2 having fine unevenness structure

surface is not especially limited so long as it is formed on the transparent substrate 1, but any

proper methods may be adopted. For example, a method of forming fine unevenness structure on

a surface of a material itself that forms the transparent resin layer 2 may be mentioned. As

illustrative examples, a method may be mentioned in which rough surfacing processing is

beforehand given to the surface of the film used for formation of the above described transparent

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resin layer 2 by proper manners, such as sandblasting, roll embossing, and chemical etching to give

fine unevenness structure to the film surface. And, a method may also be mentioned in which

additional coating of another transparent resin layer 2 is separately given on the transparent resin

layer 2, and fine unevenness structure is given by a transfer method with metal mold etc. onto the

transparent resin layer surface concerned. Furthermore, as shown in Figure 2 Figure 1, fine

unevenness structure is given by dispersing fine particles 3 in the transparent resin layer 2 may be

mentioned. In the formation method of these fine unevenness structures, two or more kinds of

methods may be used in combination, and a layer may be formed in which different type of fine

unevenness structures are compounded on the surface. In the formation method of the above

described resin coated 2, a method of forming a transparent resin layer 2 that contains the fine

particles 3 dispersed therein is preferable in view of easiness and reliability of formation of fine

unevenness structure.

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